PCCP

CORRECTION

View Article Online
View Journal | View Issue

Cite this: *Phys. Chem. Chem. Phys.*, 2018, **20**, 2914

Correction: Direct characterization of graphene doping state by *in situ* photoemission spectroscopy with Ar gas cluster ion beam sputtering

Dong-Jin Yun,[a] Seyun Kim,[b] Changhoon Jung,[a] Chang-Seok Lee,[a] Hiesang Sohn,[c] Jung Yeon Won,[a] Yong Su Kim,[a] JaeGwan Chung,[a] Sung Heo,[a] Seong Heon Kim,[a] Minsu Seol*[d] and Weon Ho Shin*[e]

DOI: 10.1039/c7cp90282d

rsc.li/pccp

Correction for 'Direct characterization of graphene doping state by *in situ* photoemission spectroscopy with Ar gas cluster ion beam sputtering' by Dong-Jin Yun *et al.*, *Phys. Chem. Chem. Phys.*, 2018, **20**, 615–622.

The authors would like to correct the grant number given in the Acknowledgements of the published article. The correct Acknowledgements should read as follows:

This work was supported by a grant from the Fundamental R&D program for Core Technology of Materials funded by the National Research Foundation (NRF) of Korea (NRF-2017R1D1A1B03034322). This work was supported by the Samsung Advanced Institute of Technology.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

[a] *Analytical Science Laboratory, Samsung Advanced Institute of Technology, 130 Samsung-ro, Yeongtong-gu, Suwon, Gyeonggi-do 16678, Republic of Korea*
[b] *Materials Research Center Samsung Advanced Institute of Technology, 130 Samsung-ro, Yeongtong-gu, Suwon, Gyeonggi-do 16678, Republic of Korea*
[c] *Department of Chemical Engineering, Kwangwoon University, 20 Kwangwoon-Ro, Nowon-Gu, Seoul 01897, Republic of Korea*
[d] *Graphene Center Samsung Advanced Institute of Technology, 130 Samsung-ro, Yeongtong-gu, Suwon, Gyeonggi-do 16678, Republic of Korea. E-mail: Minsu.seol@samsung.com*
[e] *Energy Materials Center, Energy & Environment Division, Korea Institute of Ceramic Engineering & Technology, 101 Soho-ro, Jinju-si, Gyeongsangnam-do 52851, Republic of Korea. E-mail: whshin@kicet.re.kr*